A Volatile Silicon-Transition-metal Compound

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MOLECULAR compounds in which silicon is linked to transition metals are little known. The organosubstituted derivatives π -C₅H₅Fe(CO)₂SiMe₃¹ and Ph₃SiMn(CO)₅² have been reported, and it has also been proposed³ that a product of the reaction between dicobalt octacarbonyl and tetravinylsilane is a compound of composition Co₃(CO)₉Si-(CH:CH₂) which presumably contains Co-Si bonds. Very recently, Chalk and Harrod⁴ have described the preparation of various R₃SiCo(CO)₄ compounds by the reaction of R₃SiH with dicobalt octacarbonyl. We now report the preparation and some properties of a simple volatile compound, silylcobalt carbonyl, SiH₃Co(CO)₄.

Iodosilane reacted readily at low temperatures with a solution containing $[Co(CO)_4]^-$ in dimethyl or diethyl ether. Fractionation *in vacuo* yielded a yellow liquid, m.p. $-53\cdot5^\circ$, b.p. (extrap.) 112°, (Found: Si, 13·8; H, 1·44; Co, 29·0%; ratio CO/Co, 4·00; *M*, 202·3. SiH₃Co(CO)₄ requires Si, 13·9; H, 1·49; Co, 29·2%; CO/Co, 4·00; *M*, 202·0). Saturated vapour pressures in the range 22—90° defined the equation; log p (mm.) = -1754/T + 7·432; decomposition was marked above 85°. Heating to 100° for $\frac{1}{2}$ hr. yielded some unchanged material (30%), hydrogen, carbon monoxide, silane, cobalt carbonyl hydride, and a dark brown solid residue. Treatment with protic reagents produced the following initial cleavage:

$$SiH_3Co(CO)_4 + HX \rightarrow SiH_3X + HCo(CO)_4$$
 (1)
(X = Cl, OH)

while alkaline hydrolysis led to evolution of all the hydrogen (free from carbon monoxide). Bromine caused complete breakdown to $SiBr_4$, HBr, CO, $COBr_2$, and $CoBr_2$). It was further shown that the equilibrium:

$$2\mathrm{SiH}_{3}\mathrm{Co}(\mathrm{CO})_{4} + \mathrm{HgI}_{2} \rightleftharpoons \mathrm{SiH}_{3}\mathrm{I} + \mathrm{Hg}[\mathrm{Co}(\mathrm{CO})_{4}]_{2} (2)$$

lies well to the right.

The value of the Si-H stretching frequency (2175 cm.⁻¹) and the position of equilibrium in (2) are consistent with a low effective electronegativity for the Co(CO)₄ group and the presence of $d\pi$ - $d\pi$ interaction in the Co-Si bond. The methyl analogue decomposes above -30° ,⁵ and it is tempting to attribute this difference in thermal stability to lack of π -bonding capability in the methyl case.

Experiments now in progress indicate that similar compounds may be formed by other later transition-metals, and that disubstituted derivatives such as $SiH_2[Co(CO)_4]_2$ behave analogously.

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